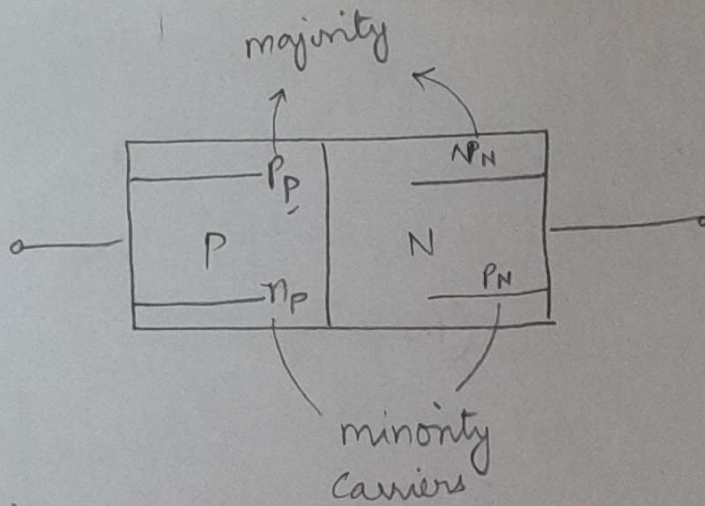
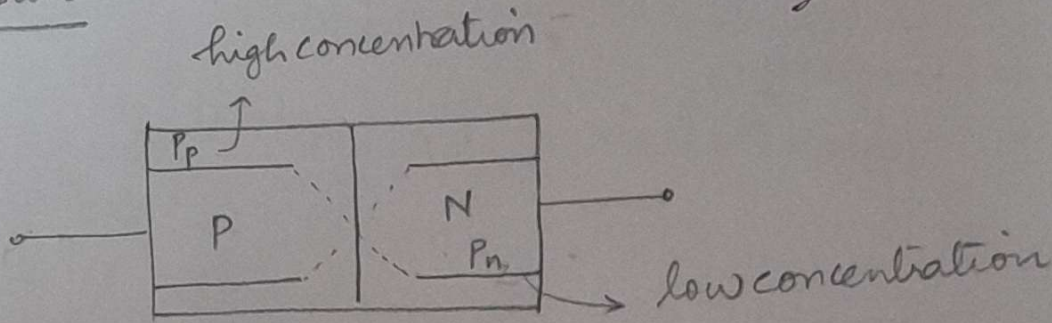


(1)

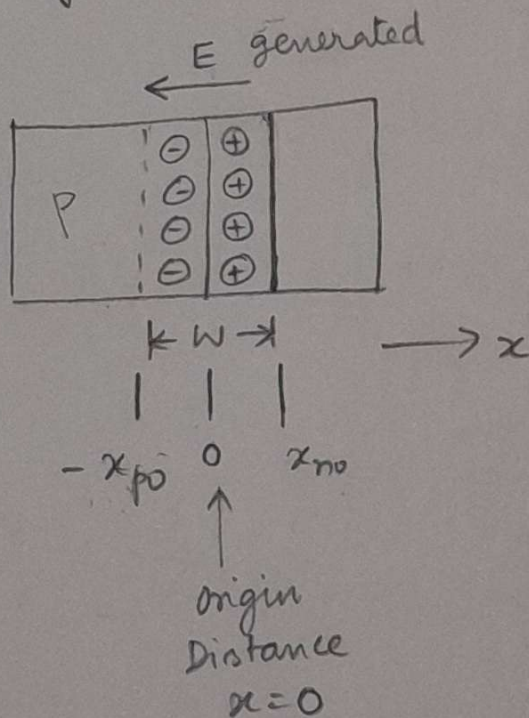
Suffix -
type of
SC



Diffusion



When they diffuse they leave behind ions.

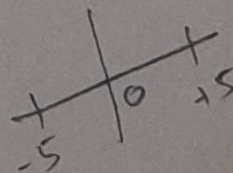


Whenever there is an internal field 'E' there is a built in potential 'V_B'

$$V_B = V_T \ln \left[\frac{N_A N_D}{n_i^2} \right]$$

N_A = acceptor concentration
 N_D = Donor concentration
 n_i = intrinsic carrier concentration

$$W = x_{no} + x_{po}$$



Derivation for Barrier Potential

Contact potential / Built in potential / Barrier potential

At $x = -x_{p0}$

hole concentration = p_p (majority)

e^- = N_p

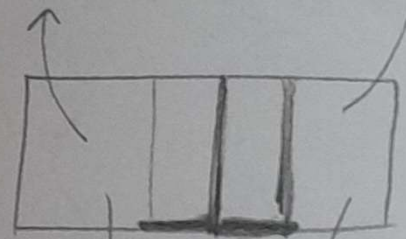
At $x = -x_{n0}$

e^- concentration = N_n (majority)

h = p_n

$E=0$

$E=0$



Due to charge neutrality.
 $E=0$

Carrier type

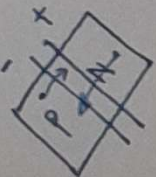
$J_p(\text{diff}) + J_p(\text{drift}) = 0$

$V_B - V_A$

$-q D_p \frac{dp}{dx} + p q \mu E = 0$

$p q \mu E = + q D_p \frac{dp}{dx}$

$V = - \int E dx$



$+ E \cdot dx = \frac{D_p}{\mu} \frac{dp}{p}$

From, Einstein relation, $\frac{D}{\mu} = V_T$ (Thermal voltage)

$= \frac{T}{11,600} \text{ (V)}$

$-x \int_{-x_{p0}}^{x_{n0}} E \cdot dx = \int_{p_p}^{p_n} \frac{V_T \cdot dp}{p}$

$\int_{-x_{p0}}^{x_{n0}} E \cdot dx = V_{x0}$

$- [V(x_{n0}) - V(-x_{p0})] = V_T [\ln(p)]_{p_p}^{p_n}$

$-V_B = V_T \ln \left[\frac{p_n}{p_p} \right]$

$$V_B = -V_T \ln \left[\frac{P_n}{P_p} \right]$$

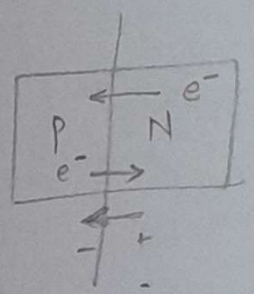
$$\Rightarrow V_B = V_T \ln \left[\frac{P_p}{P_n} \right] \quad \text{--- (1)}$$

WKT when $N_A \gg n_i$

$$P_p = \frac{N_A}{N_D}$$

$$P_n = \frac{n_i^2}{N_D}$$

$$N_n \cdot P_n = n_i^2$$



Acc = holes

$$N_n \cdot P_n = n_i^2$$

$$\therefore V_B = V_T \ln \left[\frac{\frac{N_A}{N_D}}{\frac{n_i^2}{N_D}} \right]$$

$$\Rightarrow V_B = V_T \ln \left[\frac{N_A N_p}{n_i^2} \right] \quad \text{--- (2)}$$

$$\frac{P_p}{P_n} = e^{\frac{V_B}{V_T}} \quad \text{--- from (1)}$$

$$\Rightarrow P_p = P_n e^{\left(\frac{V_B}{V_T} \right)}$$

$$= P_n e^{\left(\frac{V_B}{K T / q} \right)}$$

$$V_T = \frac{K T}{q}$$

Voltage produced within the PN Jn due to the action of temperature

$$P_p = P_n e^{\left(\frac{V_B q}{K T} \right)}$$

$$N_n = N_p e^{\frac{V_B q}{K T}}$$

(26 mV at room temperature)

Note:

$$n_n = n_p e^{V_0/V_T} \quad \text{--- I}$$

$$p_p = p_n e^{V_0/V_T} \quad \text{--- II}$$

$$\frac{\text{I}}{\text{II}} = \frac{n_n}{p_p} = \frac{n_p e^{V_0/V_T}}{p_n e^{V_0/V_T}}$$

$$= n_n p_n = n_p \cdot p_p = n_i^2 \rightarrow \text{Mass action law}$$

$$\underline{V_B = 0.7V}$$

$$k = 1.381 \times 10^{-23}$$

For,

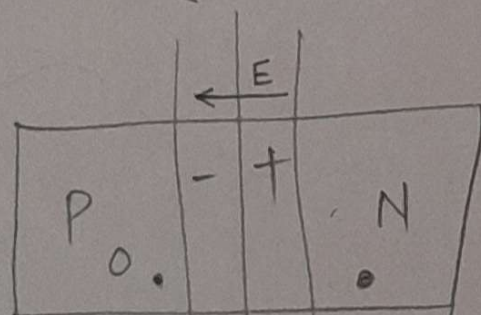
$$\text{Si} \quad n_i = 1.5 \times 10^{10} / \text{cm}^3$$

$$N_A = N_D = 10^{16} / \text{cm}^3$$

$$V_T = 25 \text{ mV (at room temperature)}$$

$$V_0 \approx 697 \text{ mV} = 0.7 \text{ V.}$$

← hole drift
← electron diffusion



$$\begin{aligned} V_B &= 26 \times 10^{-3} \\ &\ln \left[\frac{10^{16} \times 10^{16}}{(1.5 \times 10^{10}) \times (1.5 \times 10^{10})} \right] \\ &26 \times 10^{-3} \times [26.82] \\ &= 0.7 \text{ V} \end{aligned}$$

1) Calculate the built in potential barrier in a PN junction. Consider a Silicon PN jn at 300K with doping densities

$$N_A = 1 \times 10^{18} \text{ cm}^{-3} ; N_D = 1 \times 10^{15} \text{ cm}^{-3}$$

Assume $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$

$$V_B = \frac{kT}{q} \ln \left[\frac{1}{\frac{n_i^2}{N_A \times N_D}} \right]$$

$$= 26 \times \ln \left[\frac{1}{\frac{1.5 \times 10^{10} \times 1.5 \times 10^{10}}{10^{18} \times 10^{15}}} \right]$$

$$= 26 \times \ln \left[\frac{10^{33}}{2.25 \times 10^{20}} \right]$$

$$= 26 \times \ln \left[\frac{1}{2.25} \times 10^{13} \right]$$

$$= 26 \times 29 \times 10^{-3}$$

$$V_B = 0.76 \text{ V}$$

$$k = 1.3806 \times 10^{-23}$$

$$T = 300$$

$$q = 1.602 \times 10^{-19}$$

$$= 2$$

$$\boxed{\frac{kT}{q} = 25.8 \text{ mV}}$$

2) Consider a Si PN junction at 300 K with doping concentration of $N_A = 10^{16} \text{ cm}^{-3}$ and $N_D = 10^{15} \text{ cm}^{-3}$. Assume that $n_i = 1.5 \times 10^{10} \text{ cm}^{-3}$. Calculate width of the space charge region in a PN junction, when a reverse bias voltage $V_R = 5 \text{ V}$ is applied.

$$\epsilon_0 = 8.854 \times 10^{-12}$$

$$\epsilon_r = 12$$

N_A

N_D

n_i

V_R

$$W = \frac{2 \epsilon_0 \epsilon_r (V_B)}{q} \left[\frac{N_A + N_D}{N_A N_D} \right]$$

$$= \frac{2 \epsilon_0 \epsilon_r (V_B + V_R)}{q} \left[\frac{N_A + N_D}{N_A N_D} \right]$$

$$W = 0.8 \mu\text{m}$$

8 $\mu\text{m} \times$
2 mm

